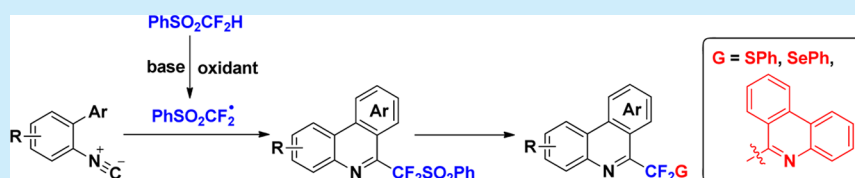


Radical (Phenylsulfonyl)difluoromethylation of Isocyanides with PhSO₂CF₂H under Transition-Metal-Free ConditionsPan Xiao,^{†,‡} Jian Rong,[†] Chuanfa Ni,[†] Junkai Guo,[†] Xinjin Li,[†] Dingben Chen,[†] and Jinbo Hu^{*,†,‡,§}[†]Key Laboratory of Organofluorine Chemistry, Shanghai Institute of Organic Chemistry, Chinese Academy of Sciences, 345 Lingling Road, Shanghai 200032, China[‡]School of Physical Science and Technology, ShanghaiTech University, 100 Haik Road, Shanghai 201210, China

Supporting Information



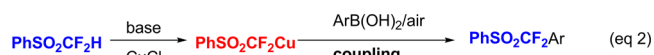
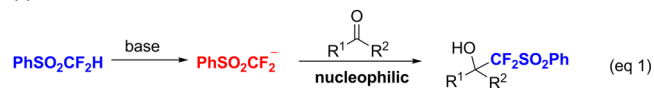
ABSTRACT: An atom-economical method for radical (phenylsulfonyl)difluoromethylation of isocyanides with PhSO₂CF₂H under transition-metal-free conditions has been developed. A PhSO₂CF₂ radical is generated through the oxidation of PhSO₂CF₂⁻ after the deprotonation of PhSO₂CF₂H in one pot. The reaction exhibits excellent functional-group tolerance and the resulting products can be further modified with the removal of a PhSO₂ group to give other CF₂-containing compounds.

The phenanthridine core is an important substructure existing in various natural products which possess a wide range of biological activities and applications.¹ Selective introduction of fluorine-bearing motifs into organic molecules, including the above-mentioned phenanthridine derivatives, may effectively enhance the latter's biological activity due to the increased lipophilicity and metabolic stability.² Therefore, it is highly desirable to develop efficient methods for the incorporation of fluorinated moieties into diverse organic structures. Among various fluoroalkyl groups, the *gem*-difluoroalkyl group has attracted particular interest, since the CF₂ moiety is known to be isosteric to the ethereal oxygen atom.³ In this respect, the PhSO₂CF₂ group is appealing based on the fact that it is a versatile functional group that can be converted to other highly useful difluorinated moieties such as difluoromethyl (-CF₂H), difluoromethylene (-CF₂-), and difluoromethylidene (=CF₂) groups.⁴ Over the past decades, nucleophilic (phenylsulfonyl)difluoromethylation of a variety of electrophiles with PhSO₂CF₂H has proved to be a powerful strategy for the synthesis of fluorinated compounds.^{5,6} For example, α -difluoromethyl alcohols can be readily prepared by nucleophilic difluoromethylation of carbonyl compounds with its anion PhSO₂CF₂⁻ (Scheme 1, eq 1).⁶ In addition, a method for copper-mediated aerobic (phenylsulfonyl)difluoromethylation of arylboronic acids with PhSO₂CF₂H has been developed that proceeds via the in situ generated PhSO₂CF₂Cu species (Scheme 1, eq 2).⁷

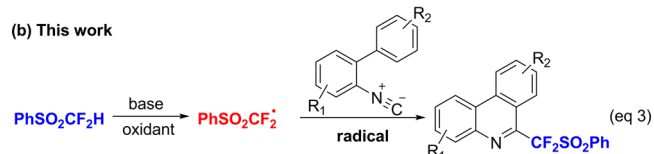
As very important reactive intermediates, fluoroalkyl radicals have attracted much attention in recent years,⁸ and many reagents, including the Langlois reagent,⁹ the Togni reagent,¹⁰ the Umemoto reagent,¹¹ the Ruppert–Prakash reagent,¹² and fluoroalkyl halides,^{5c,13} have been used for the radical fluoroalkylation. However, to the best of our knowledge,

Scheme 1. (Phenylsulfonyl)difluoromethylation of Organic Molecules with PhSO₂CF₂H

(a) Previous work



(b) This work



there is no report on the direct radical fluoroalkylation with the readily available PhSO₂CF₂H reagent.^{5c} Considering that the generation of PhSO₂CF₂ radical by the homolytic cleavage of the F₂C–H bond of PhSO₂CF₂H is a formidable challenge, we envisioned that the radical could be generated through the oxidation of PhSO₂CF₂⁻ after the deprotonation of PhSO₂CF₂H in one pot. We realized that the difficulty in this chemistry lies in how to find suitable oxidants and strong bases and how to make them well compatible in the same reaction system. Recently, PhI(OAc)₂-mediated radical fluoroalkylation of arenes,^{12d} unactivated alkenes^{12c,14} or isocyanides^{12e} under silver-mediated, -catalyzed or -free conditions has been developed, which inspired us to develop an atom-economical method for radical (phenylsulfonyl)difluoromethylation with

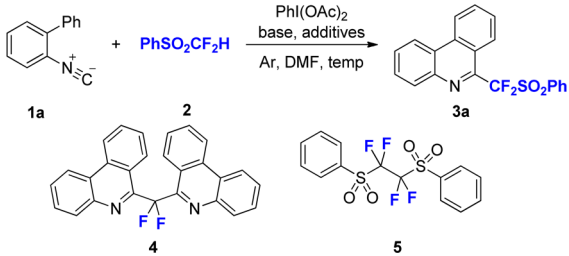
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PhSO₂CF₂H using PhI(OAc)₂ as a mild oxidant under transition-metal-free conditions (Scheme 1, eq 3).

At the onset of our investigation, isocyanide **1a** was used as a model substrate, LiHMDS/THF as a base, and PhI(OAc)₂ as an oxidant and DMF as solvent, respectively, for the radical (phenylsulfonyl)difluoromethylation with PhSO₂CF₂H (Table 1, entry 1). We were pleased to find that the desired product **3a**

Table 1. Optimization of Reaction Conditions^a



| entry | base | additive (1.0 equiv) | temp (°C) | 3a, yield ^b (%) |
|-----------------|-----------------|--|-----------|----------------------------|
| 1 | LiHMDS | | -50 | 13 |
| 2 | NaHMDS | | -50 | 7 |
| 3 | <i>t</i> -BuOK | | -50 | 19 |
| 4 | <i>t</i> -BuONa | | -50 | 41 |
| 5 ^c | <i>t</i> -BuONa | | -50 | 0 |
| 6 | <i>t</i> -BuONa | | -60 | 39 |
| 7 | <i>t</i> -BuONa | | -40 | 39 |
| 8 | <i>t</i> -BuONa | | -30 | 34 |
| 9 | <i>t</i> -BuONa | | -10 | 21 |
| 10 | <i>t</i> -BuONa | | rt | 5 |
| 11 ^d | <i>t</i> -BuONa | | -50 | 54 |
| 12 ^d | <i>t</i> -BuONa | NaHCO ₃ | -50 | 58 |
| 13 ^d | <i>t</i> -BuONa | Na ₂ CO ₃ | -50 | 61 |
| 14 ^d | <i>t</i> -BuONa | Cs ₂ CO ₃ | -50 | 70 |
| 15 ^d | <i>t</i> -BuONa | K ₃ PO ₄ | -50 | 62 |
| 16 ^d | <i>t</i> -BuONa | BQ ^e | -50 | 58 |
| 17 ^d | <i>t</i> -BuONa | I ₂ ^e | -50 | 67 |
| 18 ^d | <i>t</i> -BuONa | Cs ₂ CO ₃ /I ₂ ^e | -50 | 78 |
| 19 ^d | <i>t</i> -BuONa | K ₃ PO ₄ /BQ ^e | -50 | 66 |
| 20 ^d | <i>t</i> -BuONa | Na ₂ CO ₃ /I ₂ ^e | -50 | 74 |

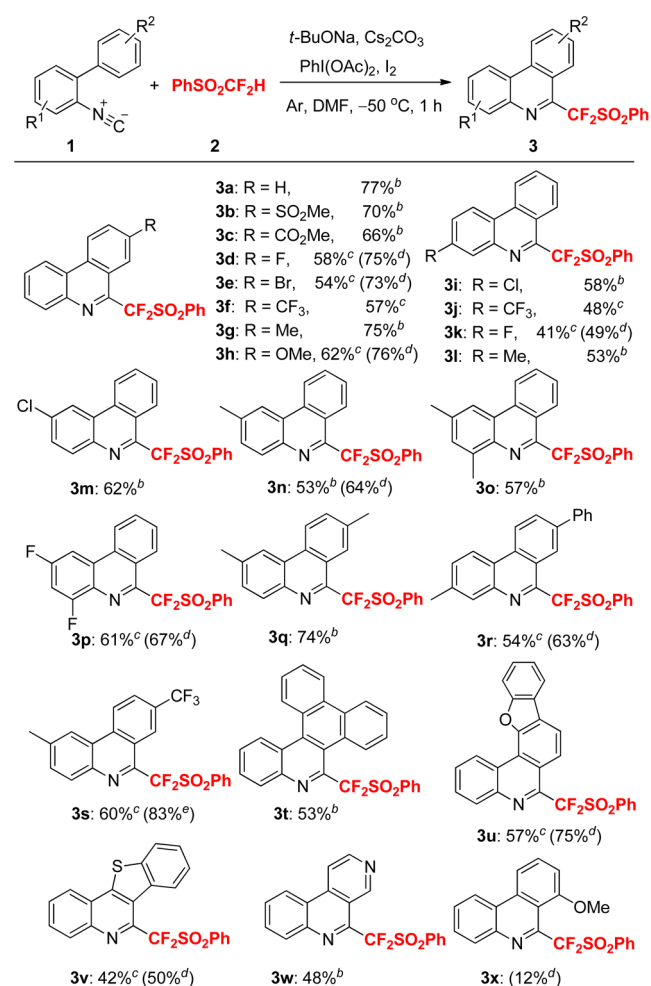
^aReaction conditions: **1a** (0.2 mmol, 1.0 equiv), **2** (2.0 equiv), PhI(OAc)₂ (4.0 equiv), base (4.0 equiv), DMF (1.0 mL), Ar, 1 h. ^bYields were determined by ¹⁹F NMR spectroscopy using PhCF₃ as an internal standard. ^c*t*-BuONa (solid) and PhI(OAc)₂ were mixed together before the addition of **2**. ^dPhI(OAc)₂ (6.0 equiv) and *t*-BuONa/DMF (2.0 mol/L, 6.0 equiv) were used. ^e0.2 equiv of additive was added.

was formed in 13% yield. Further optimization of the reaction conditions showed that *t*-BuONa/DMF solution (2.0 M) gave a higher yield than other bases (Table 1, entries 1–4). It was noteworthy that no desired product **3a** could be detected when mixing *t*-BuONa (solid) and PhI(OAc)₂ together before the addition of **2** (Table 1, entry 5), indicating that charging sequence is very important. The reaction was quite sensitive to temperature, and the yield was gradually increased as the temperature decreased; we found that -50 °C was the optimal temperature for the reaction (Table 1, entries 4 and 6–10). At the same time, we found that although the side product **4** can be diminished at low temperatures, another side product **5** (via homocoupling of the radical intermediate) was increasingly formed (for details, see the Supporting Information). The yield was further improved effectively by increasing the amount of

PhI(OAc)₂ and *t*-BuONa/DMF to 6.0 equiv and adding some additives (Table 1, entries 11–20), which turned out to be useful to inhibit the generation of side product **5** to some extent (for details, see the SI). Furthermore, the addition of weak bases could increase the conversion of PhSO₂CF₂H (Table 1, entries 12–15 and 18–20), and the reaction could be further promoted in the presence of I₂ (Table 1, entries 17, 18, and 20). Finally, the optimal yield of **3a** (78% yield) was obtained when employing Cs₂CO₃ (1.0 equiv) as a base and I₂ (0.2 equiv) as an additive (Table 1, entry 18).

With the optimized reaction conditions in hand, we further investigated the substrate scope of the current method and found that a variety of isocyanides **1** could be transformed into the corresponding products **3** in moderate to good yields (Scheme 2). Both electron-withdrawing groups (**3b–f**) and electron-donating groups (**3g,h**) on the *para*-position of the R²-substituted phenyl ring were compatible under the reaction

Scheme 2. Radical (Phenylsulfonyl)difluoromethylation of Isocyanides^a

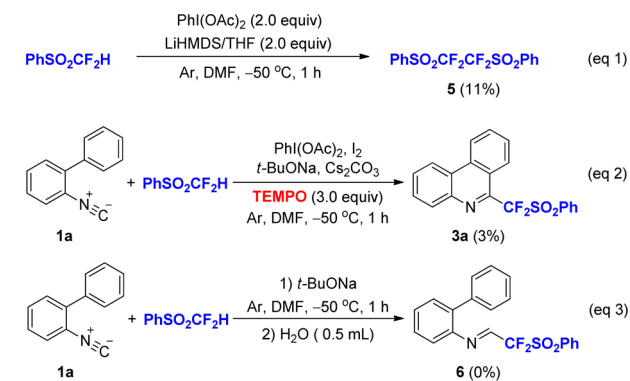


^aGeneral conditions: isocyanides **1** (0.2 mmol), PhSO₂CF₂H (0.4 mmol), PhI(OAc)₂ (1.2 mmol), *t*-BuONa/DMF (2.0 M, 0.6 mL), Cs₂CO₃ (0.2 mmol) and I₂ (0.04 mmol) in 1.3 mL of DMF at -50 to -60 °C for 1 h. ^bIsolated yields were given by column chromatography on silica. ^cIsolated yields were given by recrystallization. ^dYields were determined by ¹⁹F NMR spectroscopy using PhCF₃ as an internal standard. ^eYields were determined by ¹⁹F NMR spectroscopy using PhOCF₃ as an internal standard.

conditions, with no significant influence on the yields of products. In the case of R¹-substituted isocyanides, the desired products were obtained in slightly lower yields when the substituents were on the *meta*- or *para*-positions (3i–n). Those with two substituents in the same or different aromatic rings gave good yields of products (3o–s). In addition to biphenyl derivatives, those fused to other aryl (3t,u) and heteroaryl (3v,w) moieties also worked well in the reaction, albeit providing the products in moderate yields. Compared with 3h, the 2-methoxy-substituted isocyanide 1x was transformed to product 3x in poor yield (12%), which might be because only one reactive site was available on the aryl ring. It was noteworthy that under optimized conditions the reaction can be easily scaled up; for example, when 10 mmol of 1a (1.79 g) was used, 54% of isolated yield of 3a (1.99 g) could be obtained after repeated recrystallization.

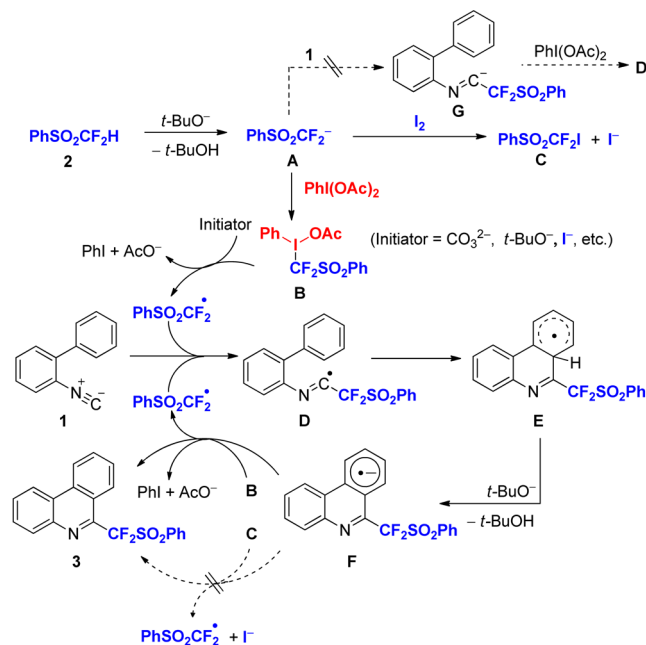
To gain more insights into this transition-metal-free radical (phenylsulfonyl)difluoromethylation reaction, we carried out some control experiments. First, in the absence of isocyanide 1a, the homocoupling product PhSO₂CF₂CF₂SO₂Ph (5) was formed in 11% yield, and a peak at –111.1 ppm was observed in a crude sample by ¹⁹F NMR spectroscopy using PhCF₃ as an internal standard (Scheme 3, eq 1). Second, the inhibition

Scheme 3. Control Experiments



experiment of 1a with TEMPO (2,2,6,6-tetramethyl-1-piperidinyloxy, 3.0 equiv), which is known as an efficient radical scavenger, was conducted under the standard reaction conditions, and the reaction was almost shut down (Scheme 3, eq 2). Similarly, when 3.0 equiv of 1,3-dinitrobenzene, which easily undergoes one electron reduction,¹⁵ was added into the standard reaction system, no desired product 3a could be detected. Third, a large amount of PhI was obtained by column chromatography on silica gel when the desired products were isolated, indicating that PhI(OAc)₂ was reduced. Fourthly, the attempt to capture the protonated product (6) of the intermediate G failed (Scheme 3, eq 3, and Scheme 4), thus ruling out the path of the oxidation of G. These experiments support the involvement of a PhSO₂CF₂ radical species in the current fluoroalkylation reaction. Finally, we probed the role of the additive I₂ in this reaction. Because a trace amount of PhSO₂CF₂I was detected after the completion of the reaction, we initially thought that PhSO₂CF₂I could serve as a PhSO₂CF₂ radical source in this reaction and the formation of PhSO₂CF₂I via iodination of PhSO₂CF₂ anion by I₂ could improve the generation of PhSO₂CF₂ radical. In fact, when I₂ was replaced by PhSO₂CF₂I (0.2 equiv), the consumption of the latter resulted in a relatively low yield (53%), even lower than that in

Scheme 4. Plausible Reaction Mechanism

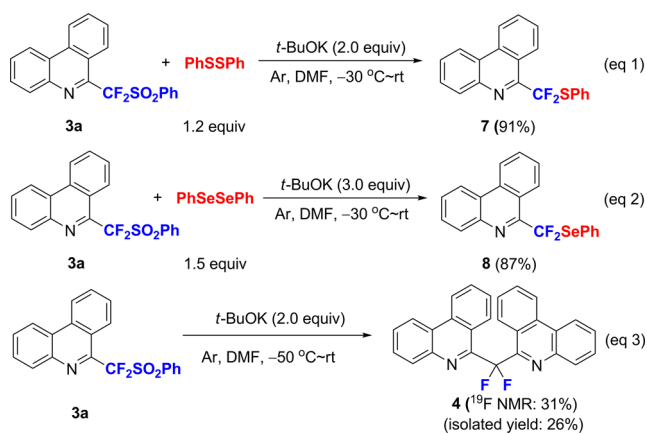


the absence of I₂, which suggested that PhSO₂CF₂I might not participate in the reaction. Therefore, we propose that the iodide ion formed from the reaction between PhSO₂CF₂ anion and I₂ may serve as an additional initiator to promote the generation of PhSO₂CF₂ radical from the hypervalent iodine intermediate B (Scheme 4).

Based on the aforementioned results, a plausible reaction mechanism is proposed in Scheme 4. After the deprotonation of PhSO₂CF₂H, the hypervalent iodine intermediate B is generated from PhSO₂CF₂ anion (A) and PhI(OAc)₂. Single-electron transfer (SET) from an initiator (such as the iodide ion in situ produced from A and I₂) to B gives PhSO₂CF₂ radical and thus initiates the reaction. Then the PhSO₂CF₂ radical adds to 1 to give the imidoyl radical D, which subsequently undergoes intramolecular radical cyclization to afford the radical intermediate E. Deprotonation of E by t-BuO⁻ provides radical anion F,^{10a,13b,16} which reacts with intermediate B through a SET process to generate product 3 and to regenerate PhSO₂CF₂ radical. A secondary path that involves the generation of PhSO₂CF₂ radical from PhSO₂CF₂I is less likely due to the inhibition effect of PhSO₂CF₂I on the reaction.

It was reported that the PhSO₂ group in some fluoroalkyl sulfones could be removed by the nucleophilic attack of alkoxide or hydroxide, and the generated fluoroalkyl anions were able to react with different electrophiles such as carbonyl compounds and disulfides.^{6b,17} We assumed that a similar type of S–C bond cleavage could occur with our products 3. As expected, the transformation of PhSO₂ group to PhS and PhSe group was accomplished successfully (Scheme 5, eqs 1 and 2). Furthermore, in the absence of other electrophiles, 3a could react with another molecule of itself to give rise to a structurally symmetrical product 4 (Scheme 5, eq 3), which is the side product observed during our optimization of reaction conditions (see Table 1 and the SI). The formation of 4 from 3a/t-BuOK/DMF is intriguing and needs further study to understand its reaction mechanism.

Scheme 5. Transformation of PhSO₂ Group to Other Functionalities



In summary, we have developed an atom-economical method for radical (phenylsulfonyl)difluoromethylation of isocyanides with PhSO₂CF₂H reagent under transition-metal-free conditions. This new strategy shows an unusual role of PhSO₂CF₂H, from which a PhSO₂CF₂ radical is formed in the presence of PhI(OAc)₂. The reaction tolerates many functional groups, and the transformation of PhSO₂ group to other groups mediated by *t*-BuOK is accomplished. Further exploration of the synthetic applications of fluoroalkyl sulfones is currently underway in our laboratory.

■ ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge on the ACS Publications website at DOI: [10.1021/acs.orglett.6b03013](https://doi.org/10.1021/acs.orglett.6b03013).

Experimental procedures and characterization data for products (PDF)

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Notes

The authors declare no competing financial interest.

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